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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09 943,199	08 29 2001	Kristy A. Campbell	M122-1672	8508

**SUITE 1300** 

601 W. FIRST AVENUE

SPOKANE, WA 99201-3828

01 16 2003

WELLS ST. JOHN ROBERTS GREGORY & MATKIN P.S.

Kristy A. Campbell

EXAMINER

VU, DAVID

ART UNIT PAPER NUMBER

DATE MAILED: 01/16/2003

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)			
•					
Office Action Summary	09/943,199	CAMPBELL ET AL.			
Office Action Summary	Examiner	Art Unit			
The MAILING DATE of this communication ap	DAVID VU	2818	ress		
Period for Reply		•			
A SHORTENED STATUTORY PERIOD FOR REPL THE MAILING DATE OF THIS COMMUNICATION.  - Extensions of time may be available under the provisions of 37 CFR 1. after SIX (6) MONTHS from the mailing date of this communication.  - If the period for reply specified above is less than thirty (30) days, a replet find the period for reply is specified above, the maximum statutory period.  - Failure to reply within the set or extended period for reply will, by statut.  - Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).  Status	136(a). In no event, however, only within the statutory minimum will apply and will expire SIX (i.e., cause the application to become date of this communication,	may a reply be timely filed  n of thirty (30) days will be considered timely.  6) MONTHS from the mailing date of this comone ABANDONED (35 U.S.C. § 133).	nmunication.		
1) Responsive to communication(s) filed on 27					
	his action is non-final.				
3) Since this application is in condition for allow closed in accordance with the practice under	vance except for forma or <i>Ex parte Quayle</i> , 193	al matters, prosecution as to the 35 C.D. 11, 453 O.G. 213.	ments is		
Disposition of Claims  4)  Claim(s) 1-89 is/are pending in the applicatio	ın				
4a) Of the above claim(s) <u>5,7,8 and 17-89</u> is/a		nsideration.			
5) Claim(s) is/are allowed.					
6) Claim(s) <u>1-4,6 and 9-16</u> is/are rejected.					
7) Claim(s) is/are objected to.					
8) Claim(s) are subject to restriction and/	or election requireme	nt.			
Application Papers					
9) ☐ The specification is objected to by the Examin					
10) ☐ The drawing(s) filed on 29 August 2001 is/are:					
Applicant may not request that any objection to the			r		
11) The proposed drawing correction filed on		o) disapproved by the Examine	1.		
If approved, corrected drawings are required in reply to this Office action.  12) The oath or declaration is objected to by the Examiner.					
, —	Adminion.				
Priority under 35 U.S.C. §§ 119 and 120	an priority under 25 LL	S.C. 8.119(a)_(d) or (f)			
13) Acknowledgment is made of a claim for foreign	gii priority under 55 o.	5.6. § 113(a)-(a) 51 (i).			
<ul><li>a) All b) Some * c) None of:</li><li>1. Certified copies of the priority documer</li></ul>	ats have been receive	d			
<ul><li>2. Certified copies of the priority documer</li><li>3. Copies of the certified copies of the priority</li></ul>			Stage		
application from the International B * See the attached detailed Office action for a lis	sureau (PCT Rule 17.2 of the certified copie	2(a)). es not received.			
14) Acknowledgment is made of a claim for domes	stic priority under 35 U	.S.C. § 119(e) (to a provisional	application).		
<ul> <li>a)  The translation of the foreign language per</li> <li>15)  Acknowledgment is made of a claim for domes</li> </ul>	rovisional application stic priority under 35 L	has been received. J.S.C. §§ 120 and/or 121.			
Attachment(s)					
<ol> <li>Notice of References Cited (PTO-892)</li> <li>Notice of Draftsperson's Patent Drawing Review (PTO-948)</li> <li>Information Disclosure Statement(s) (PTO-1449) Paper No(s)</li> </ol>	5) 🔲 No	erview Summary (PTO-413) Paper No(s tice of Informal Patent Application (PTC ner:			

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### **DETAILED ACTION**

### Election/Restrictions

- 1. Applicant's election without traverse of Species I in Paper No. 7 is acknowledged.
- 2. Claims 5, 7-8 and 17-89 are withdrawn from further consideration pursuant to 37 CFR 1.142(b) as being drawn to a nonelected species. There being no allowable generic or linking claim. Election was made without traverse in Paper No. 7.

# Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (e) the invention was described in-
- (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effect under this subsection of a national application published under section 122(b) only if the international application designating the United States was published under Article 21(2)(a) of such treaty in the English language;
- (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that a patent shall not be deemed filed in the United States for the purposes of this subsection based on the filing of an international application filed under the treaty defined in section 351(a).
- 3. Claims 1-4, 6 and 11-16 are rejected under 35 U. S. C. 102(e) as being anticipated by Kozicki et al., (US 2002/0168820).

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Regarding claims 1-4, 6 and 11-16, Kozicki et al., in related text ([0039]) and figures (Figures. 1-2) disclose a method of forming a chalcogenide comprising device, comprising: forming a first conductive electrode material 130 on a substrate 110; forming a metal doped chalcogenide 140/160, an exemplary chalcogenide glass with dissolved metal includes a solid solution of As<sub>x</sub>S<sub>1-x</sub>Ag, Ge<sub>x</sub>Se<sub>1-x</sub>Ag, Ge<sub>x</sub>S<sub>1-x</sub> Ag, As<sub>x</sub>S<sub>1-x</sub>--Cu, Ge<sub>x</sub>Se<sub>1-x</sub>--Cu, Ge<sub>x</sub>S<sub>1-x</sub>--Cu, where x ranges from about 0.1 to about 0.5 other chalcogenide materials including silver, copper, zinc, combinations of these materials, and the like (See [0062] and [0053]) exposing the outer surface of the metal doped chalcogenide electrode material to an atmosphere having a temperature elevated from ambient room temperature for a period of time effective to form a passivating material 155 on the metal doped chalcogenide comprising material outer surface (See [0048]); and depositing a second conductive electrode material over the passivating material, and forming the second conductive electrode material 120 into an electrode of the device.

## Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

- (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 4. Claims 9-10 are rejected under 35 U.S.C. 103(a) as being unpatentable over Kozicki et al., (US 2002/0168820).

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Kozicki et al., in related text ([0048]), disclose the passivation 155 may be formed by exposing ion conductor 140 to an oxidizing environment at a temperature of about 300-800°C or by exposing ion conductor 140 to an oxidizing environment in the presence of radiation having an energy greater than the band gap of the ion conductor material. The passivation 155 may also be deposited using physical vapor deposition or chemical vapor deposition.

Kozicki et al., discloses all claimed subject matter, but fails to expressly mention the thickness of the passivation layer. The specific thickness of the passivation layer does not provide any critical or unexpected results to the chalcogenide comprising device. Rather, it is merely an obvious design choice determinable by routine experimentation. In Aller, the court stated, "Where the general conditions of a claim are disclosed in the prior art, it is not inventive to discover the optimum or workable ranges by routine experimentation." In re Aller, 220 F.2d 454, 456 105 USPQ 233,235 (CCPA 1995).

### Conclusion

5. Any inquiry concerning this communication or earlier communications from the examiner should be directed to David Vu whose telephone number is (703) 305-0391. The examiner can normally be reached on Monday-Friday from 8:00am to 5:00pm. If attempt to reach the examiner by telephone are unsuccessful, the examiner's supervisor, David Nelms., can be reached on (703) 308-4910.

DV

David Vu.

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